

CHASING ABNORMALITIES ON TIME SERIES FOR PREDICTIVE MAINTENANCE AND ADVANCED PROCESS CONTROL

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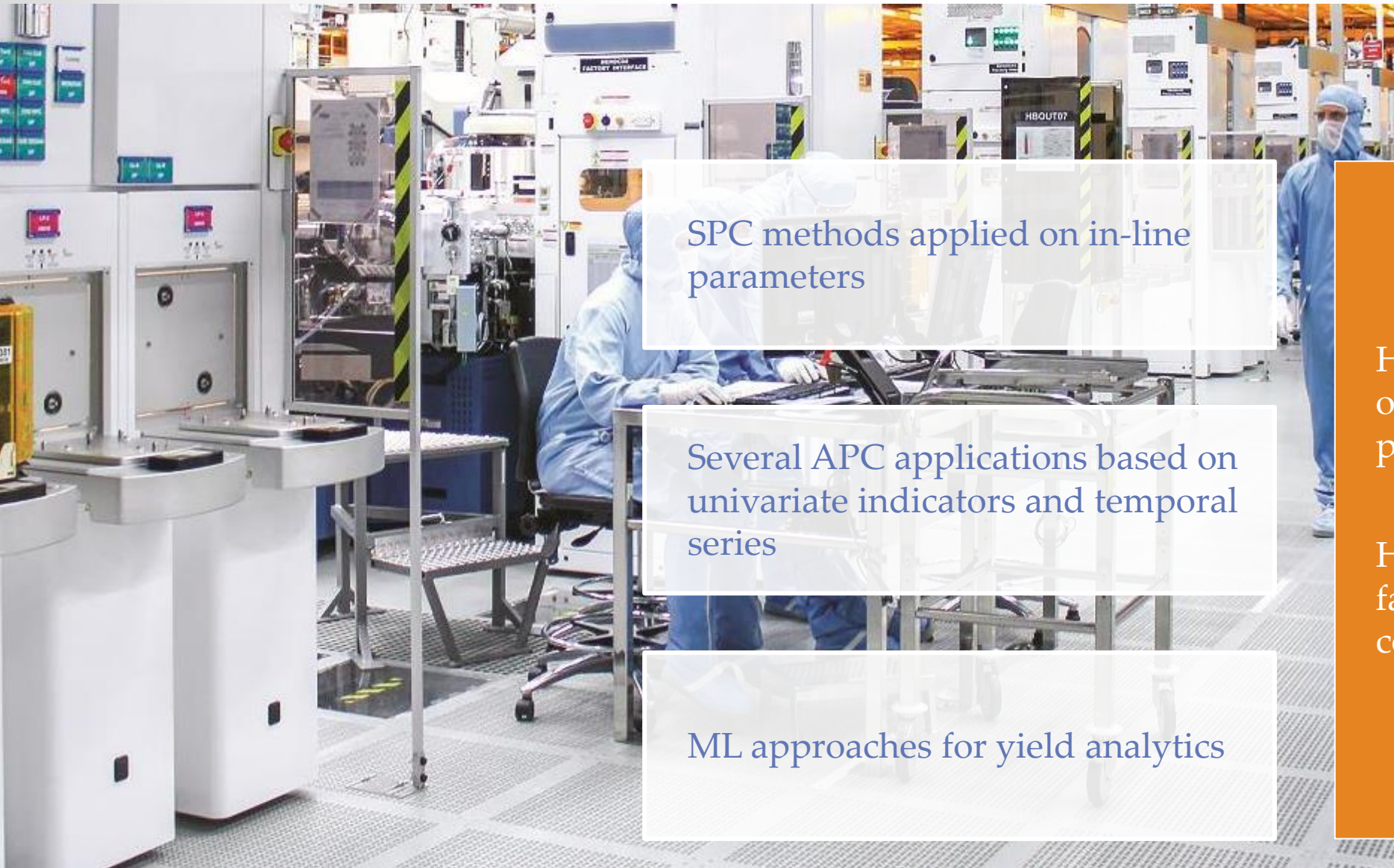
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Context: equipment control and quality control



SPC methods applied on in-line parameters

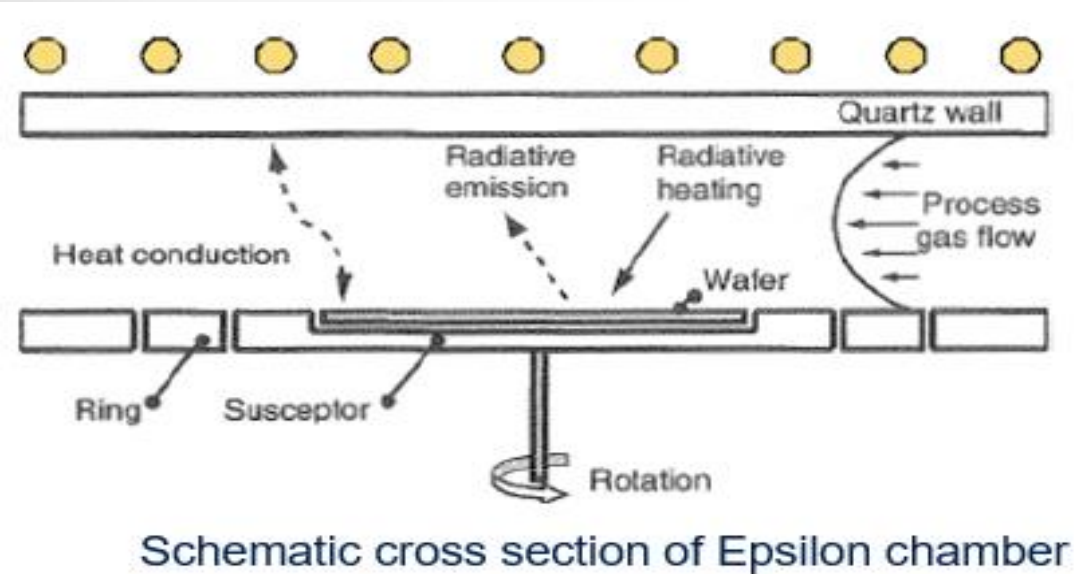
Several APC applications based on univariate indicators and temporal series

ML approaches for yield analytics

How to improve accuracy on equipment failures predictions?

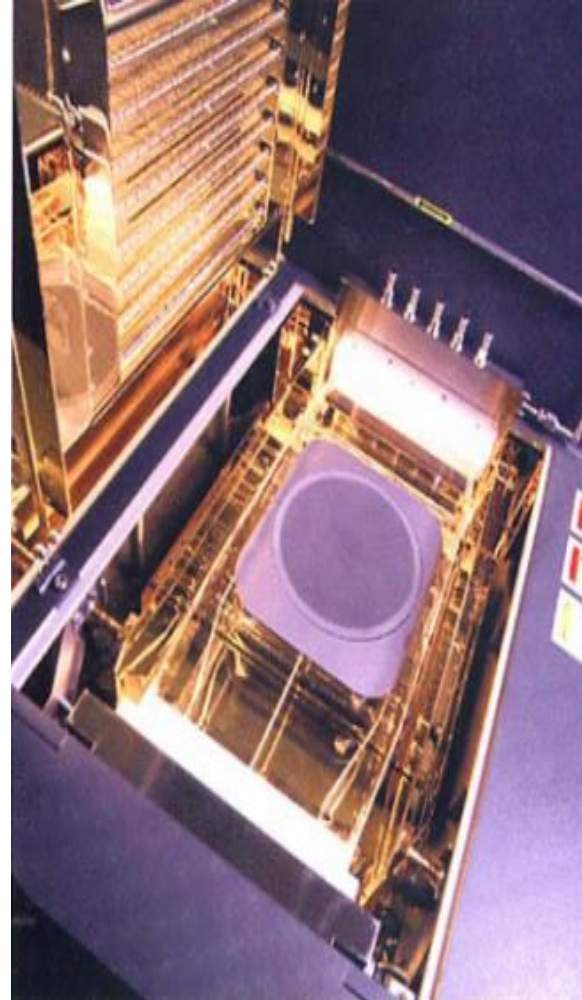
How to catch drifts and failures on closed loop control systems?

Use case: thermal drift on epitaxy reactor



Epitaxy Growth: CVD Deposition

The grown material is crystalline and reproducing the crystal arrangement of the substrate underneath.

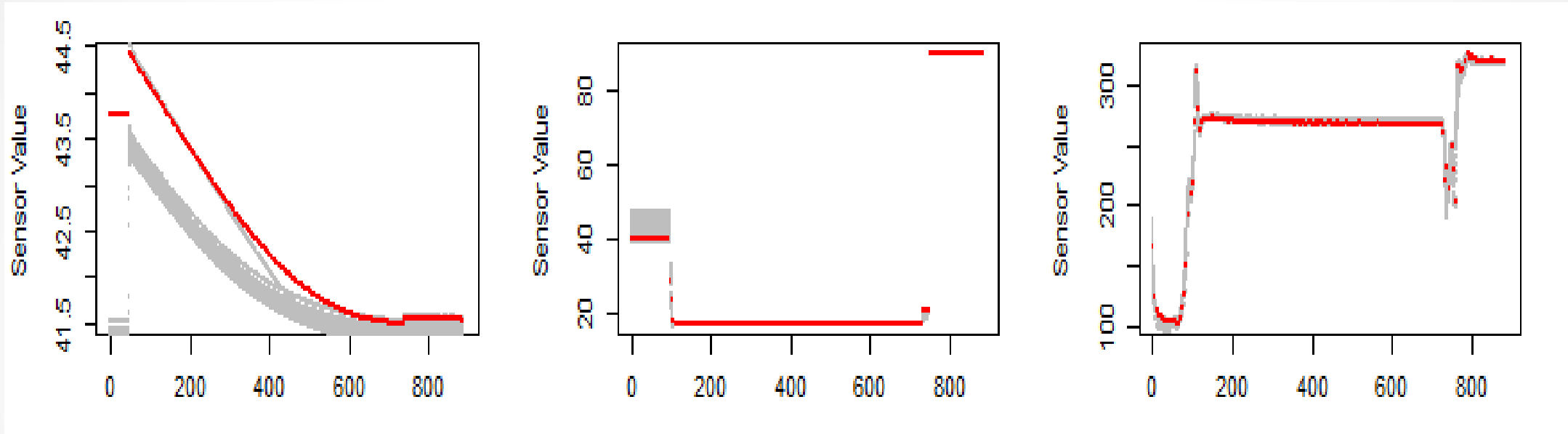


Thermal drift

Heating systems based on closed loop approach guarantee the best compromise to reach temperature setpoint.

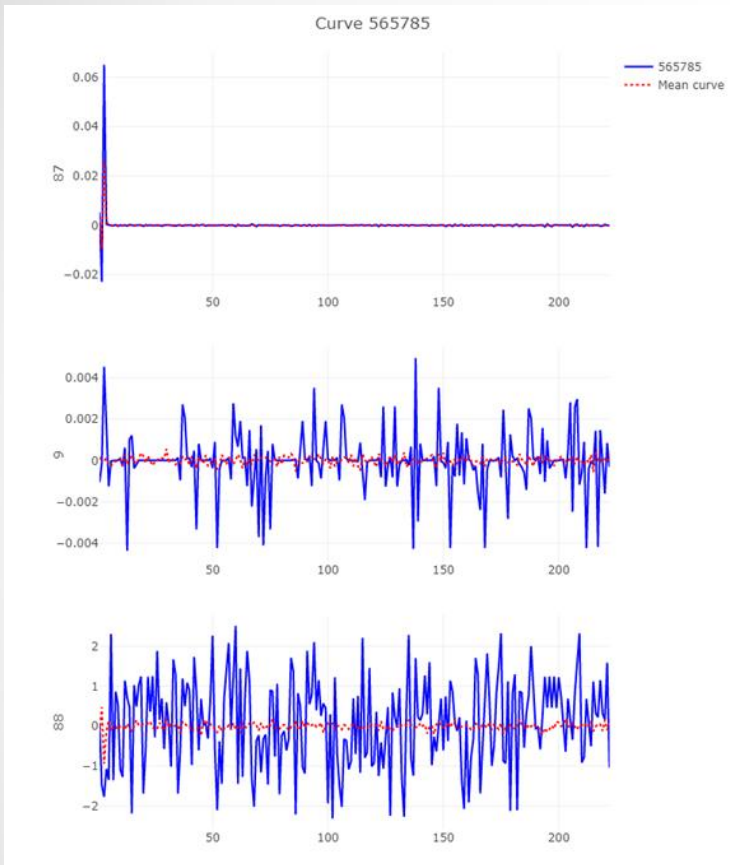
Power applied on lamps banks is varying and modulating, it is not trivial to distinguish regular trends from anomalous ones.

What is functional data?

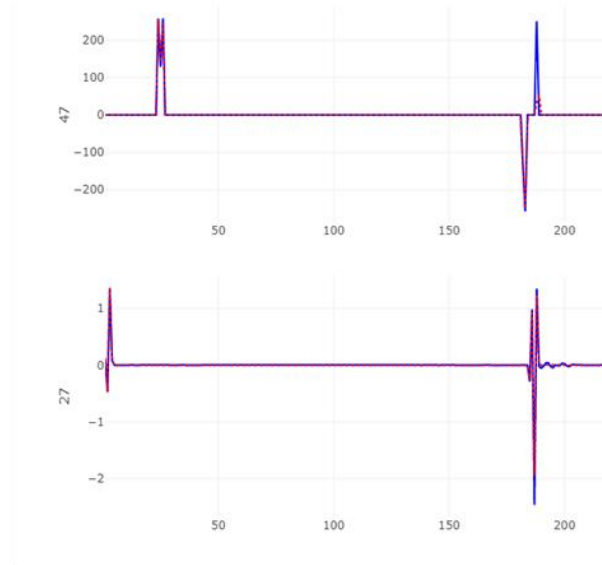


Functional data are curves, usually temporal curves also called time series, above is an example of 3 sensors

CHAM: processing data – step 1



3 sensors with abnormal
time series
(the blue curves)



The innovation: time series
are transformed in a real
valued number, a “distance”

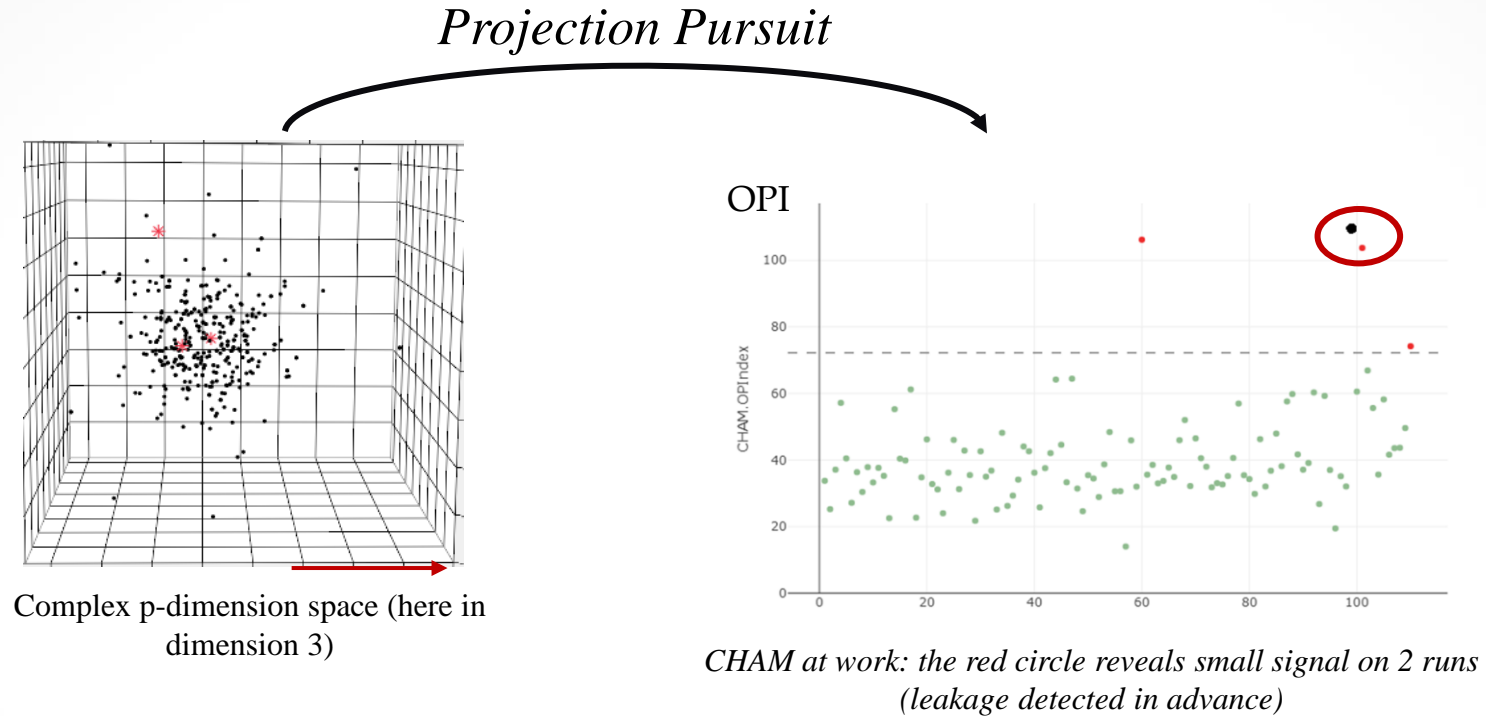
For each sensor

1- CHAM computes a « standard
curve » based on the data collected
from all the runs

2- CHAM assigns to each run a
value that reflects the 'distance'
between the actual curve of that
run and the standard curve

Patent Pending

CHAM: processing data – step 2



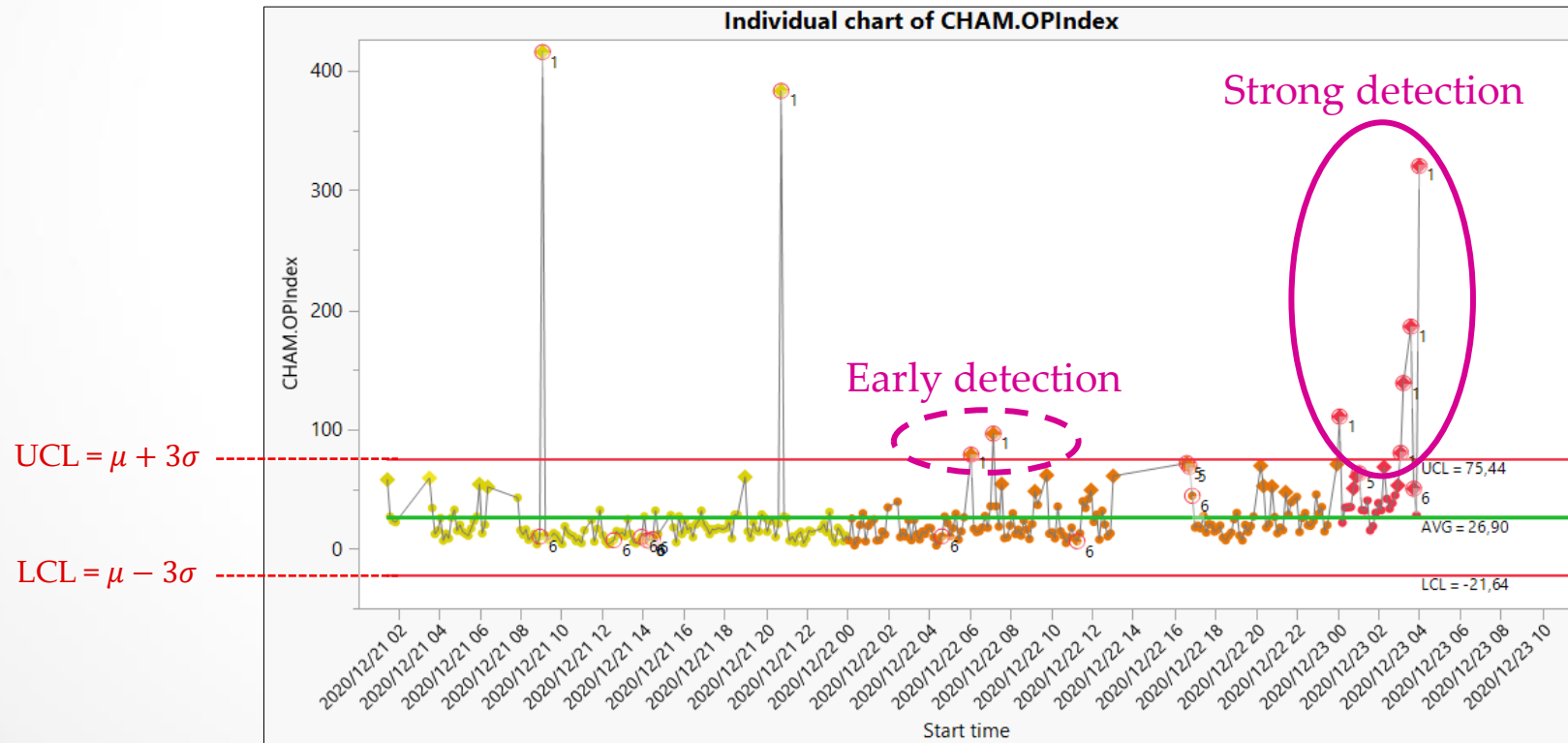
Result for each unit (sensor) are projected from *a p-dimensional space to a 1-dimensional space*: $P(x_i)$ is the Optimal Projection Index

CHAM algorithm summary

- Following steps are performed, unsupervised method
 0. Imputation of missing data & preprocessing
 1. Curve modeling and distance calculations
 2. Projection Pursuit for abnormal curves detection
 3. OPI (Optimal Projection Index) calculation from steps 1&2
 4. Outlier detection on the OPI
 - Reminder
 - CHAM step 1 is a fully new method, patent pending
 - CHAM step 2 is different from FPCA (different goal) and from the Mahalanobis distance or Hotelling T^2
- (these methods work poorly when the parameters are correlated and numerous, this is often the case with sensors)

Epitaxy use case - OPI control chart

- CHAM runs on December 2020 data (full month)
- Among the 2326 observations 27 outliers are identified by CHAM, i.e., **1.16%** of the observations
- Occurrence of the failure : 23rd of December 2020, around 4 am
- OPI Control chart : 2020/12/21 to 2020/12/23 (1 day prior failure)

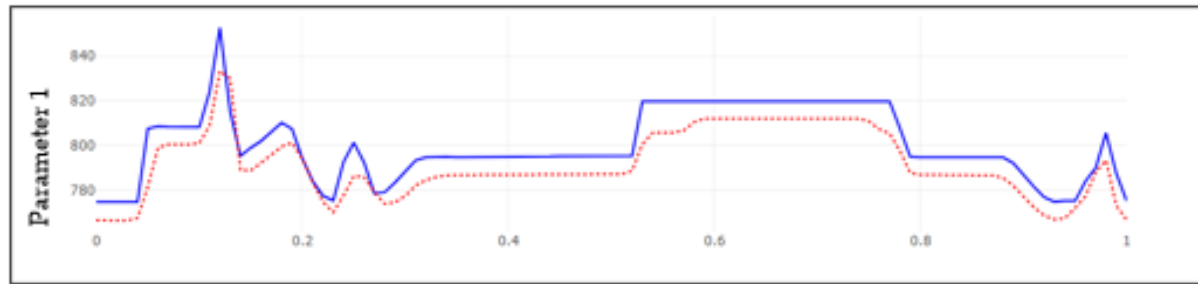


Control chart representation highlights the irregular patterns detected by CHAM's OPI near the failure occurrence

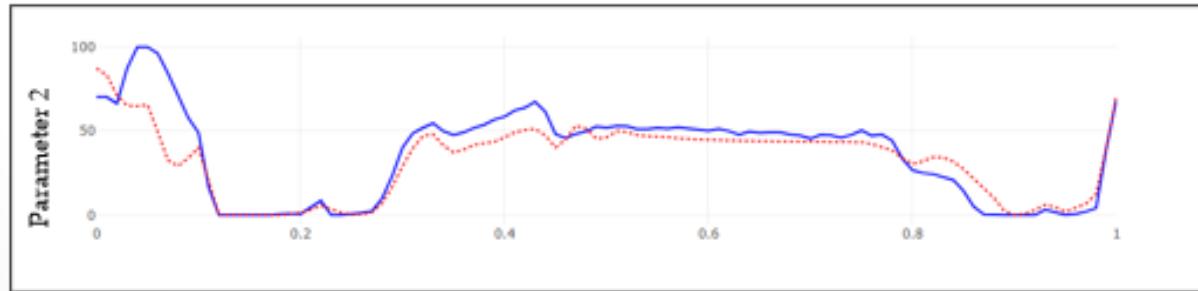
Epitaxy use case - contributors

- Contributors are the parameters **most involved in the OPI out of control**
- Example of 2 contributors:** associated to early/strong detection patterns

Parameter n°1



Parameter n°2

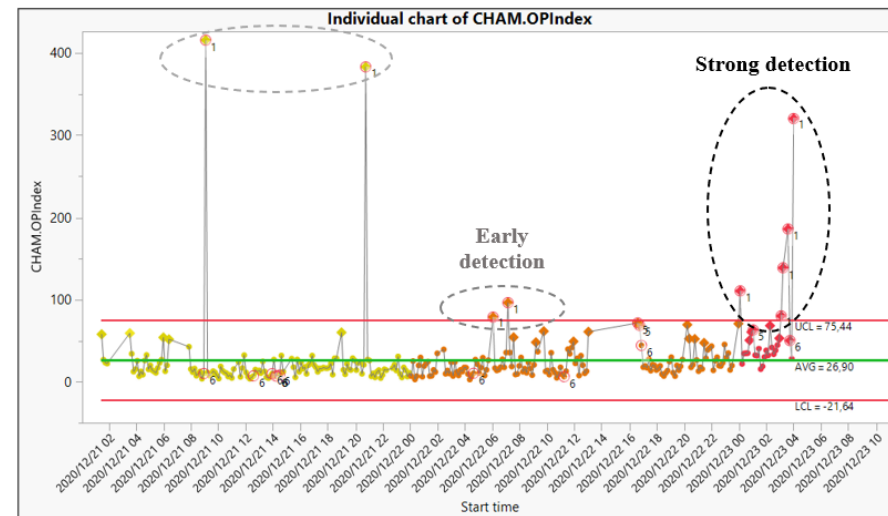


--- *Mean curve
(all observations)*

— *Observation with
out-of-control OPI*

Conclusion and opportunities

- Good results on epitaxy data: failure caught in advance
- CHAM is being deployed in pilot production at ST Catania



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Opportunities for cross-fertilization between different industries

- During MADEin4 project CHAM was also used in automotive industry, on engine quality control tests
- Lesson learnt:
 - The number of sensors was clearly lower
 - **The alignment method developed by ippon for semiconductor is being reused for automotive engine control on time series**
 - CHAM is also efficient on quality control time series
 - Statistics is universal!





QUESTIONS?